

ABSTRACT OF THE DISCLOSURE

A tool for lifting a pad, such as a CMP polish pad, is provided that includes a jaw that has an upper jaw portion and a lower jaw portion. The lower jaw portion has a sloped upper surface for slidably receiving a portion of the pad. A first member is pivotally coupled to the jaw. A
5 second member is pivotally coupled to the first member. The second member has a surface opposite to the sloped surface of the lower jaw portion. The surface is operable to clamp the portion of the pad against the sloped surface when the first member is pivoted upwards.